FIG. 1

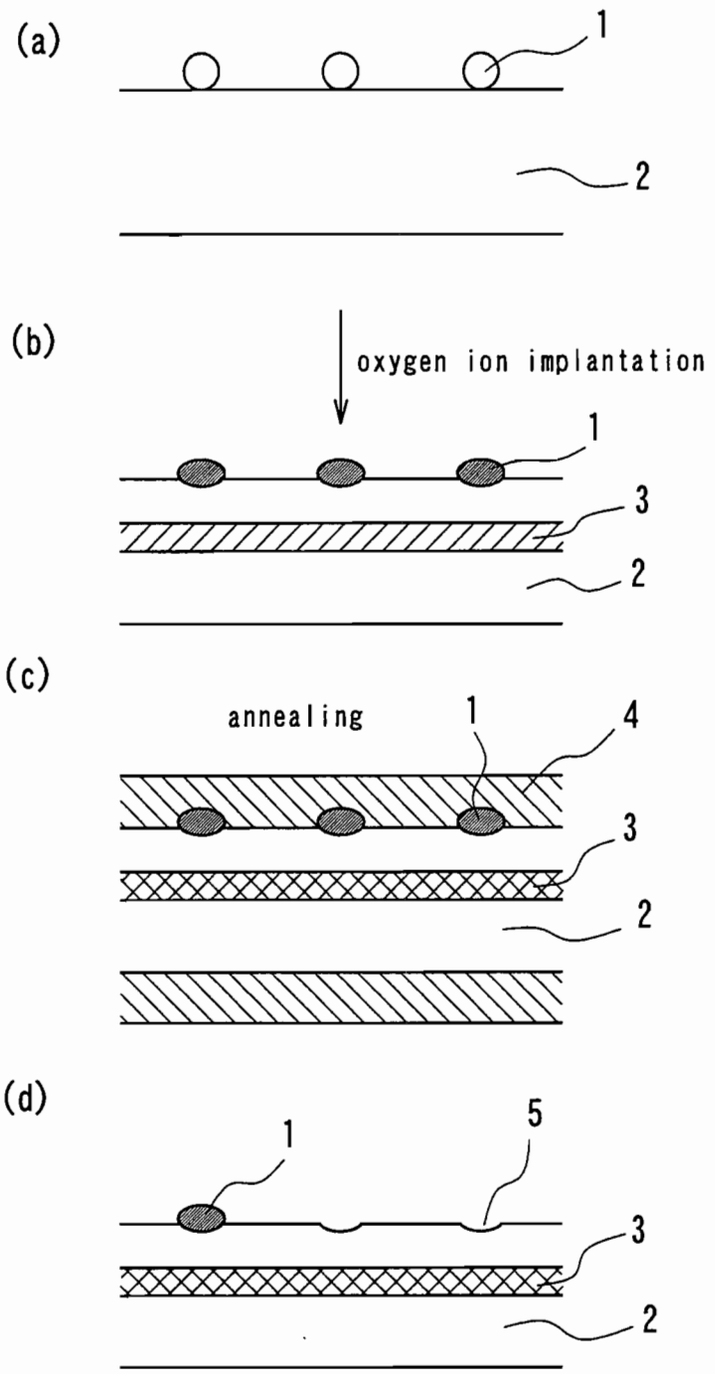


FIG. 2

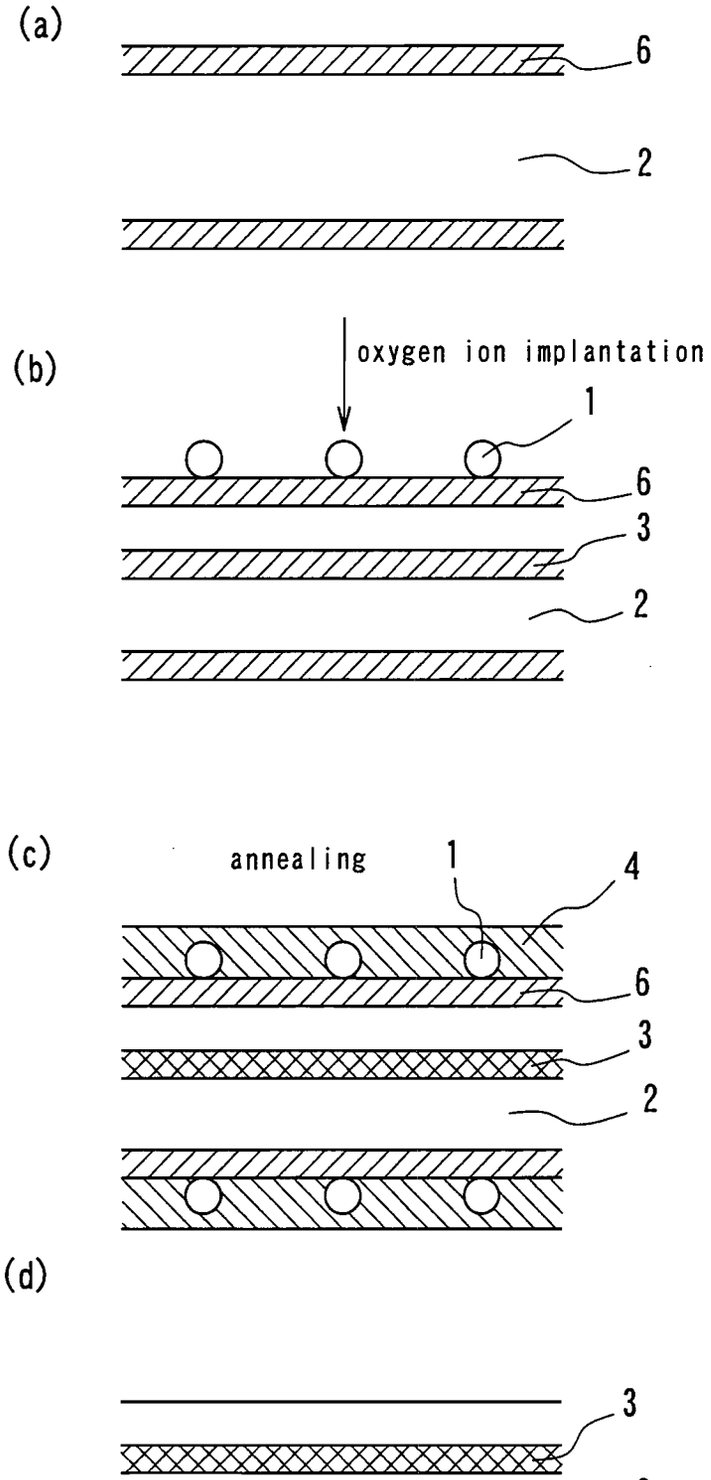


FIG. 3

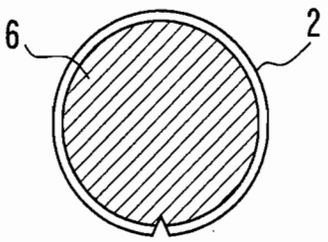
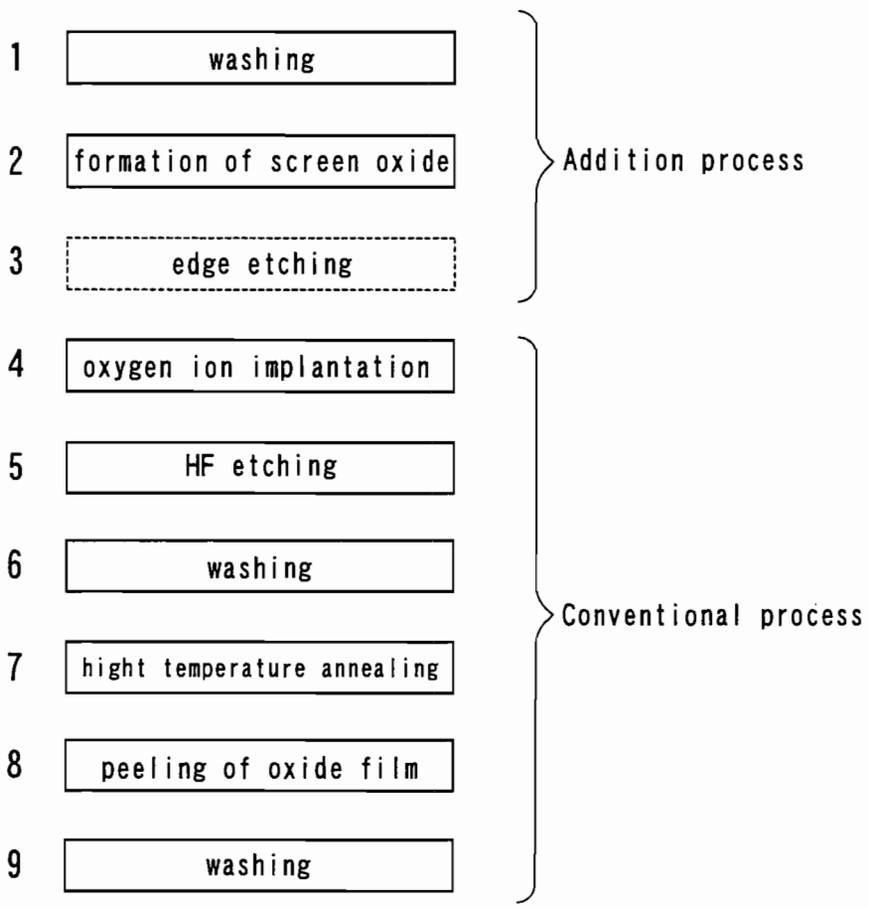

6
2

FIG. 4


1
washing
2
formation of screen oxide
3
edge etching
Addition process
4
oxygen ion implantation
5
HF etching
6
washing
7
hight temperature annealing
8
peeling of oxide film
9
washing
Conventional process